PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Syo-ichi TAKAMIZAWA et al.

Application No.: New U.S. National Stage of PCT/JP2004/012179

Filed: May 5, 2006 Docket No.: 127101

For: METHOD FOR PRODUCING SILICON EPITAXIAL WAFER

PRELIMINARY AMENDMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Please consider the following:

Amendments to the Specification;

Amendments to the Claims as reflected in the listing of claims;

Remarks.